



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

January 22, 2002

In re the Application of

Masaru MITSUI et al.

Application No.: 09/502,472

Filed: April 21, 2000 Group Art Unit:

Examiner:

Y. Clarke

1752

Docket No.: 105875

PHOTOMASK BLANK, PHOTOMASK, METHODS OF MANUFACTURING THE SAME

AND METHOD OF FORMING MICROPATTERN

LARGE ENTITY PETITION FOR 1st - 3rd EXTENSION OF TIME UNDER 37 C.F.R. §1.136(a) AND TRANSMITTAL OF FEE UNDER 37 C.F.R. §1.17

Director of the U.S. Patent and Trademark Office Washington, D.C. 20231

Sir:

For:

Transmitted herewith is a response to the outstanding Official Action in the above-identified patent application. The shortened statutory period having expired November 22, 2001, an extension of time for a period of 2 months is hereby requested. Attached hereto is our Check No. 127080 in the amount of \$400.00 in payment for:

Extension fee for response within first month pursuant to §1.136(a) (\$110.00)

Extension fee for response within second month pursuant to §1.136(a) (\$400.00)

Extension fee for response within third month pursuant to §1.136(a) (\$920.00)

The Director is hereby authorized to charge any additional fee or credit any overpayment associated with this communication to Deposit Account No. 15-0461. Two copies of this petition are enclosed.

01/28/2002 CV0111 00000091 09502472

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400.00 GP

Registration No. 27,0

Respectfully submitted,

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JAO:JSA:DML/rxg

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DEPOSIT ACCOUNT USE **AUTHORIZATION** Please grant any extension necessary for entry; Charge any fee due to our Deposit Account No. 15-0461

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